

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

LEUCHTE

Application No. 10/579,550

Filed: June 20, 2006



Confirmation No. 3962

Group Art Unit: 1793

Examiner: ZHENG, L.

For: **METHOD FOR COVERING COPPER WITH PATINA**

TRANSMITTAL LETTER

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Submitted herewith for filing in the U.S. Patent and Trademark Office is the following:

- (1) Transmittal Letter; and
- (2) Response to Restriction Requirement.

If an Extension of Time under 37 CFR §1.136 is required and has not been separately petitioned, please consider this Transmittal Letter as including a petition for such Extension of Time and as a further authorization to charge any fee for such Extension of Time, as may be required by 37 CFR §1.17, to Deposit Account No. 14-0112. Also, please charge any fee deficiency, or credit any overpayment, in connection with this matter to Deposit Account No. 14-0112.

Respectfully submitted,
THE NATH LAW GROUP

Date: Aug 28, 2008

THE NATH LAW GROUP

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Mail Stop Amendment
Attorney Docket No. 27407U

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In re patent application of:

LEUCHTE	Confirmation No.	3962
Serial No. 10/579,550	Art Unit:	1793
Filed: June 20, 2006	Examiner:	ZHENG, L.

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RESPONSE TO RESTRICTION REQUIREMENT DATED AUGUST 6, 2008

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is a full and complete response to the Office Action having a mailing date of August 6, 2008. The one month shortened statutory period to respond will expire on September 6, 2008, making this a timely filed response to the outstanding Office Action.

In view of the following election and remarks, the Applicants respectfully request that the Examiner conduct a first substantive examination on the merits.